# **KAF-0402**

# 768 (H) x 512 (V) Full Frame CCD Image Sensor

#### Description

The KAF–0402 Image Sensor is a high performance area CCD (charge-coupled device) image sensor with 768 (H)  $\times$  512 (V) photoactive pixels designed for a wide range of image sensing applications.

The sensor incorporates true two-phase CCD technology, simplifying the support circuits required to drive the sensor as well as reducing dark current without compromising charge capacity. The sensor also utilizes the TRUESENSE Transparent Gate Electrode to improve sensitivity compared to the use of a standard front side illuminated polysilicon electrode.

Optional microlenses focus the majority of the light through the transparent gate, increasing the optical response further.

#### Table 1. GENERAL SPECIFICATIONS

Parameter	Typical Value
Architecture	Full Frame CCD, Enhanced Response
Total Number of Pixels	784 (H) × 520 (V)
Number of Active Pixels	768 (H) × 512 (V) = approx. 0.4 Mp
Pixel Size	9.0 $\mu m$ (H) $\times$ 9.0 $\mu m$ (V)
Active Image Size	6.91 mm (H) $\times$ 4.6 mm (V) 8.3 mm (Diagonal) 1/2" Optical Format
Die Size	8.4 mm (H) × 5.5 mm (V)
Aspect Ratio	3:2
Saturation Signal	100,000 electrons
Quantum Efficiency (with Microlens)	Peak: 77% 400 nm: 45%
Quantum Efficiency (No Microlens)	Peak: 65% 400 nm: 30%
Output Sensitivity	10 μV/e <sup>-</sup>
Read Noise	15 electrons
Dark Current	< 10 pA/cm <sup>2</sup> at 25°C
Dark Current Doubling Temperature	6.3°C
Dynamic Range	76 dB
Charge Transfer Efficiency	> 0.99999
Blooming Suppression	None
Maximum Date Rate	10 MHz
Package	CERDIP Package (Sidebrazed)
Cover Glass	Clear or AR Coated, 2 Sides

NOTE: Parameters above are specified at T =  $25^{\circ}$ C unless otherwise noted.



## **ON Semiconductor®**

www.onsemi.com



#### Figure 1. KAF–0402 Full Frame CCD Image Sensor

#### Applications

- Digitization
- Medical
- Scientific

#### **ORDERING INFORMATION**

See detailed ordering and shipping information on page 2 of this data sheet.

## **ORDERING INFORMATION**

#### Table 2. ORDERING INFORMATION – KAF–0402 IMAGE SENSOR

Part Number	Description	Marking Code
KAF-0402-AAA-CB-B1	Monochrome, No Microlens, CERDIP Package (Sidebrazed), Clear Cover Glass (No Coatings), Grade 1	
KAF-0402-AAA-CB-AE	Monochrome, No Microlens, CERDIP Package (Sidebrazed), Clear Cover Glass (No Coatings), Engineering Sample	
KAF-0402-AAA-CP-B1	Monochrome, No Microlens, CERDIP Package (Sidebrazed), Taped Clear Cover Glass (No Coatings), Grade 1	KAF–0402–AAA Serial Number
KAF-0402-AAA-CP-B2	Monochrome, No Microlens, CERDIP Package (Sidebrazed), Taped Clear Cover Glass (No Coatings), Grade 2	
KAF-0402-AAA-CP-AE	Monochrome, No Microlens, CERDIP Package (Sidebrazed), Taped Clear Cover Glass (No Coatings), Engineering Sample	
KAF-0402-ABA-CD-B1	Monochrome, Telecentric Microlens, CERDIP Package (Sidebrazed), Clear Cover Glass with AR Coating (Both Sides), Grade 1	
KAF-0402-ABA-CD-B2	Monochrome, Telecentric Microlens, CERDIP Package (Sidebrazed), Clear Cover Glass with AR Coating (Both Sides), Grade 2	
KAF-0402-ABA-CD-AE	Monochrome, Telecentric Microlens, CERDIP Package (Sidebrazed), Clear Cover Glass with AR Coating (Both Sides), Engineering Sample	KAF-0402-ABA
KAF-0402-ABA-CP-B1	Monochrome, Telecentric Microlens, CERDIP Package (Sidebrazed), Taped Clear Cover Glass (No Coatings), Grade 1	Serial Number
KAF-0402-ABA-CP-B2	Monochrome, Telecentric Microlens, CERDIP Package (Sidebrazed), Taped Clear Cover Glass (No Coatings), Grade 2	
KAF-0402-ABA-CP-AE	Monochrome, Telecentric Microlens, CERDIP Package (Sidebrazed), Taped Clear Cover Glass (No Coatings), Engineering Sample	

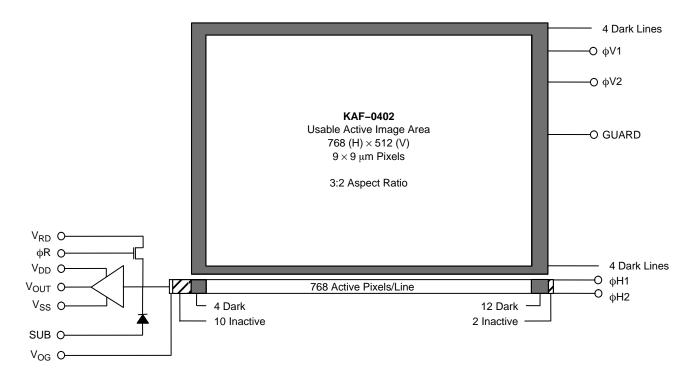
## Table 3. ORDERING INFORMATION – EVALUATION SUPPORT

Part Number	Description
KAF-0402-12-5-A-EVK	Evaluation Board (Complete Kit)

See the ON Semiconductor *Device Nomenclature* document (TND310/D) for a full description of the naming convention used for image sensors. For reference documentation, including information on evaluation kits, please visit our web site at <u>www.onsemi.com</u>.

## **DEVICE DESCRIPTION**

## Architecture



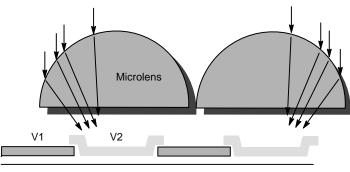


The sensor consists of 784 parallel (vertical) CCD shift registers each 520 elements long. These registers act as both the photosensitive elements and as the transport circuits that allow the image to be sequentially read out of the sensor. The parallel (vertical) CCD registers transfer the image one

#### Microlenses

Microlenses are formed along each row. They are effectively half of a cylinder centered on the transparent gates, extending continuously in the row direction. They act line at a time into a single 796-element (horizontal) CCD shift register. The horizontal register transfers the charge to a single output amplifier. The output amplifier is a two-stage source follower that converts the photo-generated charge to a voltage for each pixel.

to direct the photons away from the polysilicon gate and through the transparent gate. This increases the response, especially at the shorter wavelengths (< 600 nm).



Silicon

Figure 3. Microlens

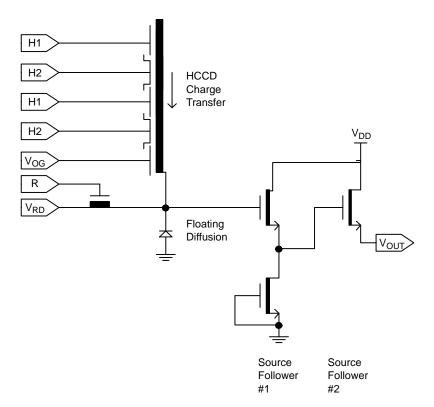


Figure 4. Output Schematic

#### **Output Structure**

Charge presented to the floating diffusion is converted into a voltage and current amplified in order to drive off-chip loads. The resulting voltage change seen at the output is linearly related to the amount of charge placed on the floating diffusion. Once the signal has been sampled by the system electronics, the reset gate ( $\phi R$ ) is clocked to remove the signal and the floating diffusion is reset to the potential applied by Vrd (see Figure 4). More signal at the floating diffusion reduces the voltage seen at the output pin. In order to activate the output structure, an off-chip load must be added to the Vout pin of the device such as shown in Figure 8.

#### Dark Reference Pixels

There are 4 light shielded pixels at the beginning of each line, and 12 at the end. There are 4 dark lines at the start of every frame and 4 dark lines at the end of each frame. Under normal circumstances, these pixels do not respond to light. However, dark reference pixels in close proximity to an active pixel can scavenge signal depending on light intensity and wavelength and therefore will not represent the true dark signal.

#### Dummy Pixels

Within the horizontal shift register are 10 leading additional pixels that are not associated with a column of pixels within the vertical register. These pixels contain only horizontal shift register dark current signal and do not respond to light. A few leading dummy pixels may scavenge false signal depending on operating conditions. There are two more dummy pixels at the end of each line.

#### **Image Acquisition**

An electronic representation of an image is formed when incident photons falling on the sensor plane create electron-hole pairs within the sensor. These photon induced electrons are collected locally by the formation of potential wells at each photogate or pixel site. The number of electrons collected is linearly dependent on light level and exposure time and non-linearly dependent on wavelength. When the pixel's capacity is reached, excess electrons will leak into the adjacent pixels within the same column. This is termed blooming. During the integration period, the  $\phi V1$ and  $\phi V2$  register clocks are held at a constant (low) level. See Figure 9.

#### **Charge Transport**

Referring again to Figure 10, the integrated charge from each photogate is transported to the output using a two-step process. Each line (row) of charge is first transported from the vertical CCD to the horizontal CCD register using the  $\phi$ V1 and  $\phi$ V2 register clocks. The horizontal CCD is presented a new line on the falling edge of  $\phi$ V2 while  $\phi$ H1 is held high. The horizontal CCD then transports each line, pixel by pixel, to the output structure by alternately clocking the  $\phi$ H1 and  $\phi$ H2 pins in a complementary fashion. On each falling edge of  $\phi$ H2 a new charge packet is transferred onto a floating diffusion and sensed by the output amplifier.

## **Physical Description**

Pin Description and Device Orientation

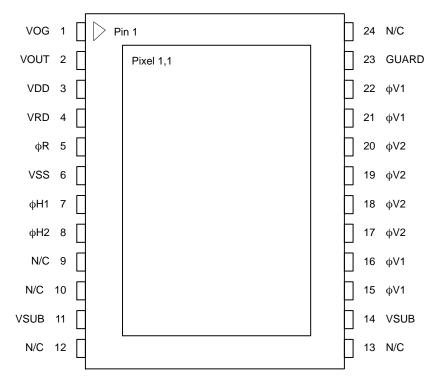


Figure 5. Pinout Diagram

Pin	Name	Description
1	VOG	Output Gate
2	VOUT	Video Output
3	VDD	Amplifier Supply
4	VRD	Reset Drain
5	φR	Reset Clock
6	VSS	Amplifier Supply Return
7	φH1	Horizontal CCD Clock – Phase 1
8	φH2	Horizontal CCD Clock – Phase 2
9	N/C	No Connection
10	N/C	No Connection
11	VSUB	Substrate
12	N/C	No Connection

Table 4.	PIN DESCRIPTION	
----------	-----------------	--

Pin	Name	Description
13	N/C	No Connection
14	VSUB	Substrate
15	φV1	Vertical CCD Clock – Phase 1
16	φV1	Vertical CCD Clock – Phase 1
17	φV2	Vertical CCD Clock – Phase 2
18	φV2	Vertical CCD Clock – Phase 2
19	φV2	Vertical CCD Clock – Phase 2
20	φV2	Vertical CCD Clock – Phase 2
21	φV1	Vertical CCD Clock – Phase 1
22	φV1	Vertical CCD Clock – Phase 1
23	GUARD	Guard Ring
24	N/C	No Connection

## **IMAGING PERFORMANCE**

#### **Specifications**

## Electro-Optical

All values measured at 25°C and nominal operating conditions. These parameters exclude defective pixels.

#### **Table 5. SPECIFICATIONS**

Description	Symbol	Min.	Nom.	Max.	Units	Notes	Verification Plan
Saturation Signal Vertical CCD Capacity Horizontal CCD Capacity Output Node Capacity	N <sub>SAT</sub>	85,000 170,000 190,000	100,000 200,000 220,000	_ 240,000 _	e <sup>-</sup> /pix	1	Design <sup>9</sup>
Quantum Efficiency (see Figure 6)		-	-	-			Design <sup>9</sup>
Photoresponse Non-Linearity	PRNL	-	1.0	2.0	%	2	
Photoresponse Non-Uniformity	PRNU	-	0.8	-	%	3	Die <sup>8</sup>
Dark Signal	J <sub>DARK</sub>		15 6	30 10	e⁻/pix/sec pA/cm²	4	Die <sup>8</sup>
Dark Signal Doubling Temperature		-	6.3	7	°C		Design <sup>9</sup>
Dark Signal Non-Uniformity	DSNU	-	15	30	e-/pix/sec	5	Die <sup>8</sup>
Dynamic Range	DR	72	76	-	dB	6	Design <sup>9</sup>
Charge Transfer Efficiency	CTE	0.99997	0.99999	-			Die <sup>8</sup>
Output Amplifier DC Offset	V <sub>ODC</sub>	V <sub>RD</sub>	V <sub>RD</sub> + 0.5	V <sub>RD</sub> + 1.0	V		Design <sup>9</sup>
Output Amplifier Sensitivity	V <sub>OUT</sub> /N <sub>e</sub> -	9	10	-	μV/e <sup>-</sup>		Design <sup>9</sup>
Output Amplifier Output Impedance	Z <sub>OUT</sub>	180	200	220	Ω		Design <sup>9</sup>
Noise Floor	n <sub>e</sub> -	-	15	20	electrons	7	

1. For pixel binning applications, electron capacity up to 330,000 can be achieved with modified CCD inputs.

2. Worst case deviation from straight line fit, between 2% and 90% of  $V_{SAT}$ . 3. One Sigma deviation of a 128 × 128 sample when CCD illuminated uniformly at half of saturation.

4. Average of all pixels with no illumination at 25°C.

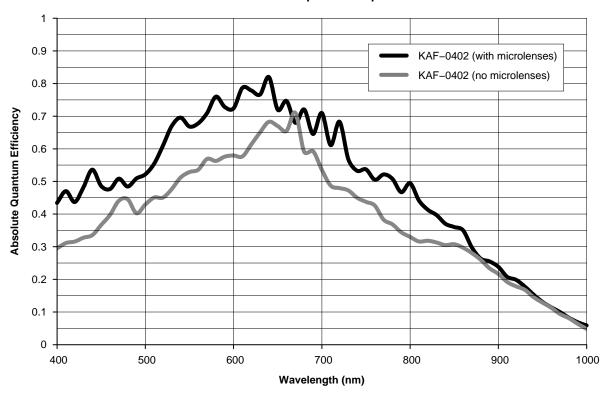
 Average dark signal of any of 11 × 8 blocks within the sensor (each block is 128 × 128 pixels).
 Average dark signal of any of 11 × 8 blocks within the sensor (each block is 128 × 128 pixels).
 20LOG (N<sub>SAT</sub> / n<sub>e</sub>-) at nominal operating frequency and 25°C.
 Noise floor is specified at the nominal pixel frequency and excludes any dark or pattern noises. It is dominated by the output amplifier power spectrum with a bandwidth =  $5 \cdot \text{pixel rate.}$ 

8. A parameter that is measured on every sensor during production testing.

9. A parameter that is quantified during the design verification activity.

## KAF-0402

## **TYPICAL PERFORMANCE CURVES**



**KAF-0402 Spectral Response** 

Figure 6. Typical Spectral Response

## **DEFECT DEFINITIONS**

ſ	Grade	Point Defect	Cluster Defect	Column Defect
ľ	C1	< 5	0	0
	C2	< 10	< 4	0

#### Table 6. SPECIFICATIONS (Defect tests performed at T = 25°C)

## Point Defects

Dark: A pixel which deviates by more than 6% from neighboring pixels when illuminated to 70% of saturation. Bright: A pixel whose dark current > 5,000 e<sup>-</sup>/pix/sec at  $25^{\circ}$ C.

## Cluster Defect

A grouping of not more than 5 adjacent point defects.

## Column Defect

A grouping of > 5 contiguous point defects along a single column.

A column containing a pixel with dark current > 12,000 e^-/pix/sec at 25°C (Bright column).

A column that does not meet the minimum vertical CCD charge capacity (Low charge capacity column).

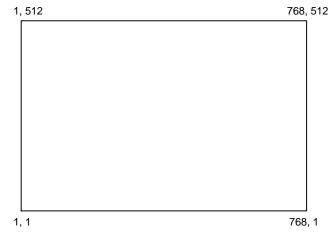
A column that loses  $> 250 e^{-1}$  under 2 ke<sup>-</sup> (Trap defect).

## Neighboring Pixels

The surrounding  $128 \times 128$  pixels or ±64 columns/rows.

## Defect Separation

Column and cluster defects are separated by no less than 2 pixels in any direction (excluding single pixel defects).





## **OPERATION**

#### **Table 7. ABSOLUTE MAXIMUM RATINGS**

Description	Symbol	Minimum	Maximum	Units	Notes
Diode Pin Voltages	V <sub>DIODE</sub>	0	20	V	1, 2
Gate Pin Voltages	V <sub>GATE1</sub>	-16	16	V	1, 3, 5
Output Bias Current	I <sub>OUT</sub>	-	-10	mA	4
Output Load Capacitance	C <sub>LOAD</sub>	-	15	pF	4

Stresses exceeding those listed in the Maximum Ratings table may damage the device. If any of these limits are exceeded, device functionality should not be assumed, damage may occur and reliability may be affected.

Referenced to pin VSUB or between each pin in this group.
 Includes pins: VRD, VDD, VSS, VOUT.

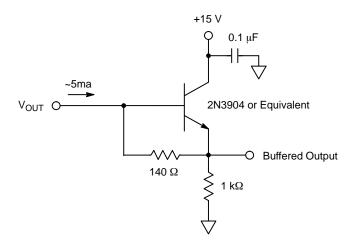
Includes pins: φV1, φV2, φH1, φH2, VOG, VLG, φR.
 Avoid shorting output pins to ground or any low impedance source during operation.

5. This sensor contains gate protection circuits to provide some protection against ESD events. The circuits will turn on when greater than 16 V appears between any two gate pins. Permanent damage can result if excessive current is allowed to flow under these conditions.

#### **Table 8. DC BIAS OPERATING CONDITIONS**

Description	Symbol	Minimum	Nominal	Maximum	Units	Maximum DC Current (mA)	Notes
Reset Drain	V <sub>RD</sub>	10	11.0	11.5	V	0.01	
Output Amplifier Return	V <sub>SS</sub>	1.5	2.0	2.5	V	-0.5	
Output Amplifier Supply	V <sub>DD</sub>	14.75	15	15.5	V	I <sub>OUT</sub>	
Substrate	V <sub>SUB</sub>	0	0	0	V	0.01	
Output Gate	V <sub>OG</sub>	3.75	4	5	V	0.01	
Guard Ring	GUARD	8.0	9.0	12.0	V	0.01	
Video Output Current	I <sub>OUT</sub>	-	-5	-10	mA	-	1

1. An output load sink must be applied to V<sub>OUT</sub> to activate output amplifier - see Figure 8.



#### Figure 8. Example Output Structure Load Diagram

## AC Operating Conditions

## Table 9. CLOCK LEVELS

Description	Symbol	Level	Minimum	Nominal	Maximum	Units	Effective Capacitance
Vertical CCD Clock – Phase 1	φV1	Low	-10.5	-10	-9.5	V	6 nF (All φV1 Pins)
Vertical CCD Clock – Phase 1	φV1	High	-0.5	0	1.0	V	6 nF (All φV1 Pins)
Vertical CCD Clock – Phase 2	φV2	Low	-10.5	-10.0	-9.5	V	6 nF (All φV2 Pins)
Vertical CCD Clock – Phase 2	φV2	High	-0.5	0	1.0	V	6 nF (All φV2 Pins)
Horizontal CCD Clock – Phase 1	φH1	Low	-4.5	-4.0	-3.5	V	50 pF
Horizontal CCD Clock – Phase 1	φH1	Amplitude	9.5	10.0	10.5	V	50 pF
Horizontal CCD Clock – Phase 2	φH2	Low	-4.5	-4.0	-3.5	V	50 pF
Horizontal CCD Clock – Phase 2	φH2	Amplitude	9.5	10.0	10.5	V	50 pF
Reset Clock	φR	Low	-3.0	-2.0	-1.75	V	5 pF
Reset Clock	φR	Amplitude	5.0	6.0	7.0	V	5 pF

1. All pins draw less than 10  $\mu$ A DC current. 2. Capacitance values relative to V<sub>SUB</sub>.

## TIMING

## **Table 10. REQUIREMENTS AND CHARACTERISTICS**

Description	Symbol	Minimum	Nominal	Maximum	Units	Notes
φH1, φH2 Clock Frequency	f <sub>H</sub>	-	4	10	MHz	1, 2, 3
Pixel Period (1 Count)	t <sub>PIX</sub>	100	250	-	ns	
φH1, φH2 Set-up Time	t <sub>¢HS</sub>	0.5	1	-	μs	
$\varphi V1, \varphi V2$ Clock Pulse Width	t <sub>¢V</sub>	1.5	2	-	μs	2
Reset Clock Pulse Width	t <sub>¢R</sub>	10	20	-	ns	4
Readout Time	t <sub>READOUT</sub>	43.7	107	-	ms	5
Integration Time	t <sub>INT</sub>	-	-	-		6
Line Time	t <sub>LINE</sub>	84.1	206	-	μS	7

1. 50% duty cycle values.

 CTE may degrade above the nominal frequency.
 Rise and fall times (10/90% levels) should be limited to 5–10% of clock period. Crossover of register clocks should be between 40–60% of amplitude.

4.  $\phi R$  should be clocked continuously.

5.  $t_{READOUT} = (520 \cdot t_{LINE})$ 6. Integration time ( $t_{INT}$ ) is user specified. Longer integration times will degrade noise performance due to dark signal fixed pattern and shot noise.

7.  $t_{\text{LINE}} = (3 \cdot t_{\phi V}) + t_{\phi HS} + (796 \cdot t_{PIX}) + t_{PIX}$ 

## **Frame Timing**

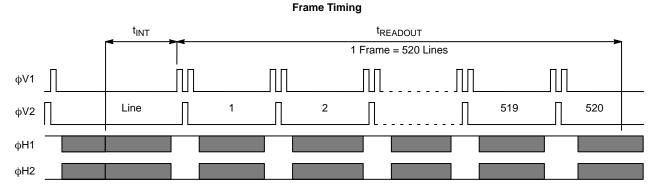


Figure 9. Frame Timing Diagram

## KAF-0402

## Line Timing and Pixel Timing

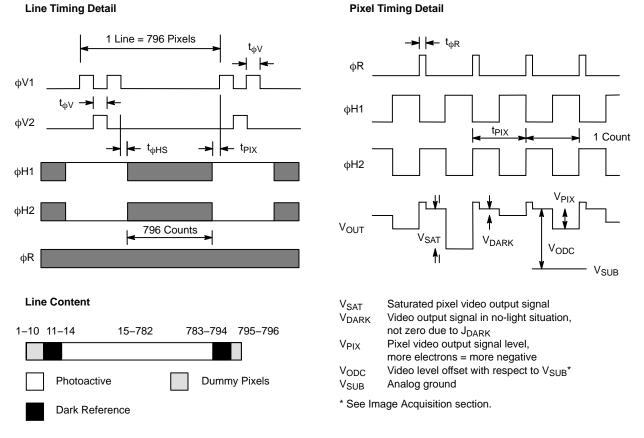


Figure 10. Line and Pixel Timing Diagrams

## STORAGE AND HANDLING

#### Table 11. STORAGE CONDITIONS

Description	Symbol	Minimum	Maximum	Units	Notes
Storage Temperature	T <sub>ST</sub>	-	100	°C	
Humidity	RH	5	90	%	1

1. T = 25°C. Excessive humidity will degrade MTTF.

For information on ESD and cover glass care and cleanliness, please download the *Image Sensor Handling and Best Practices* Application Note (AN52561/D) from www.onsemi.com.

For information on soldering recommendations, please download the Soldering and Mounting Techniques Reference Manual (SOLDERRM/D) from www.onsemi.com. For quality and reliability information, please download the *Quality & Reliability* Handbook (HBD851/D) from <u>www.onsemi.com</u>.

For information on device numbering and ordering codes, please download the *Device Nomenclature* technical note (TND310/D) from <u>www.onsemi.com</u>.

For information on Standard terms and Conditions of Sale, please download <u>Terms and Conditions</u> from <u>www.onsemi.com</u>.

#### **MECHANICAL INFORMATION**

#### **Completed Assembly**

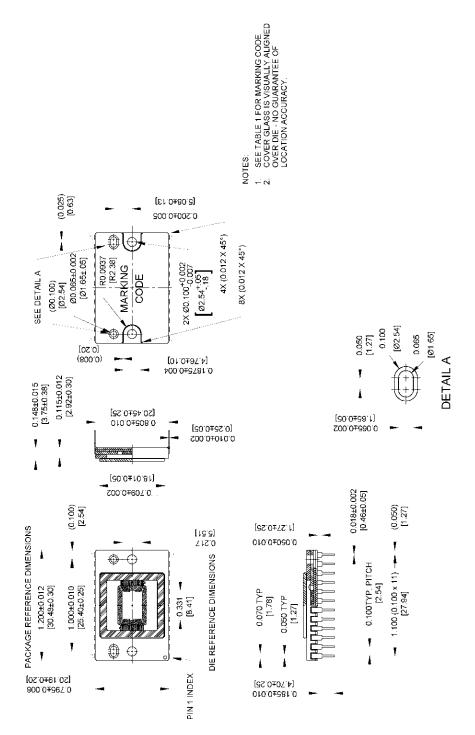


Figure 11. Completed Assembly (1 of 2)

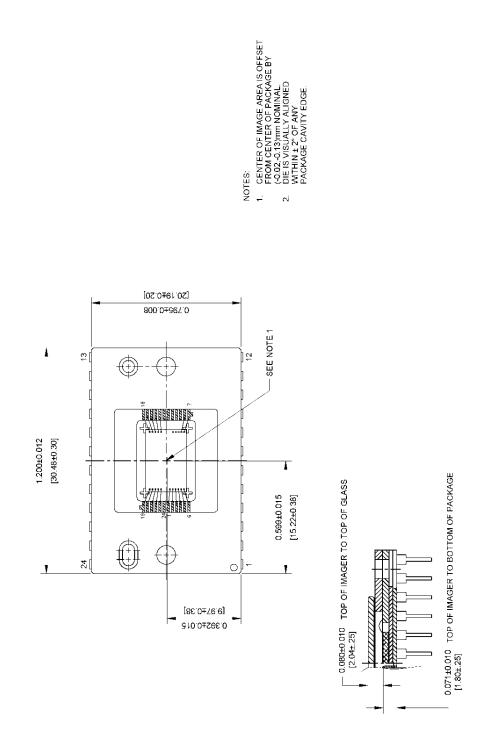


Figure 12. Completed Assembly (2 of 2)

ON Semiconductor and the use are registered trademarks of Semiconductor Components Industries, LLC (SCILLC) or its subsidiaries in the United States and/or other countries. SCILLC owns the rights to a number of patents, trademarks, copyrights, trade secrets, and other intellectual property. A listing of SCILLC's product/patent coverage may be accessed at www.onsemi.com/site/pdt/Patent-Marking.pdf. SCILLC reserves the right to make changes without further notice to any products herein. SCILLC makes no warranty, representation or guarantee regarding the suitability of its products for any particular purpose, nor does SCILLC assume any liability arising out of the application or use of any product or circuit, and specifically disclaims any and all liability, including without limitation special, consequential or incidental damages. "Typical" parameters which may be provided in SCILLC data sheets and/or specifications can and do vary in different applications and actual performance may vary over time. All operating parameters, including "Typicals" must be validated for each customer application by customer's technical experts. SCILLC does not convey any license under its patent rights nor the rights of others. SCILLC products are not designed, intended, or authorized for use as components in systems intended for surgical implant into the body, or other applications intended to support or sustain life, or for any other application in which the failure of the SCILLC product areate a situation where personal injury or death may occur. Should Buyer purchase or use SCILLC brows to rany such unintended or unauthorized application, Buyer shall indemnify and hold SCILLC and its officers, employees, subsidiaries, and distributors harmless against all claims, costs, damages, and expenses, and reasonable attorney fees arising out of, directly or indirectly, any claim of personal injury or death associated with such unintended or unauthorized use, even if such claim alleges that SCILLC was negligent regarding the design or man

#### PUBLICATION ORDERING INFORMATION

#### LITERATURE FULFILLMENT:

Literature Distribution Center for ON Semiconductor P.O. Box 5163, Denver, Colorado 80217 USA Phone: 303–675–2175 or 800–344–3860 Toll Free USA/Canada Fax: 303–675–2176 or 800–344–3867 Toll Free USA/Canada Email: orderlit@onsemi.com N. American Technical Support: 800–282–9855 Toll Free USA/Canada Europe, Middle East and Africa Technical Support:

Phone: 421 33 790 2910 Japan Customer Focus Center Phone: 81–3–5817–1050 ON Semiconductor Website: www.onsemi.com

Order Literature: http://www.onsemi.com/orderlit

For additional information, please contact your local Sales Representative



#### ООО "ЛайфЭлектроникс"

ИНН 7805602321 КПП 780501001 Р/С 40702810122510004610 ФАКБ "АБСОЛЮТ БАНК" (ЗАО) в г.Санкт-Петербурге К/С 3010181090000000703 БИК 044030703

Компания «Life Electronics» занимается поставками электронных компонентов импортного и отечественного производства от производителей и со складов крупных дистрибьюторов Европы, Америки и Азии.

С конца 2013 года компания активно расширяет линейку поставок компонентов по направлению коаксиальный кабель, кварцевые генераторы и конденсаторы (керамические, пленочные, электролитические), за счёт заключения дистрибьюторских договоров

Мы предлагаем:

- Конкурентоспособные цены и скидки постоянным клиентам.
- Специальные условия для постоянных клиентов.
- Подбор аналогов.
- Поставку компонентов в любых объемах, удовлетворяющих вашим потребностям.
- Приемлемые сроки поставки, возможна ускоренная поставка.
- Доставку товара в любую точку России и стран СНГ.
- Комплексную поставку.
- Работу по проектам и поставку образцов.
- Формирование склада под заказчика.
- Сертификаты соответствия на поставляемую продукцию (по желанию клиента).
- Тестирование поставляемой продукции.
- Поставку компонентов, требующих военную и космическую приемку.
- Входной контроль качества.
- Наличие сертификата ISO.

В составе нашей компании организован Конструкторский отдел, призванный помогать разработчикам, и инженерам.

Конструкторский отдел помогает осуществить:

- Регистрацию проекта у производителя компонентов.
- Техническую поддержку проекта.
- Защиту от снятия компонента с производства.
- Оценку стоимости проекта по компонентам.
- Изготовление тестовой платы монтаж и пусконаладочные работы.



Тел: +7 (812) 336 43 04 (многоканальный) Email: org@lifeelectronics.ru

#### www.lifeelectronics.ru